

Supplementary information

Overlayer deposition-induced control of oxide ion concentration in SrFe_{0.5}Co_{0.5}O_{2.5} oxygen sponges

Joonhyuk Lee,^a Younghak Kim,^b Jinyoung Cho,^c Hiromichi Ohta^{*d} and Hyoungjeen Jeen^{*ae}

^aDepartment of Physics, Pusan National University, Busan 46241, Korea

^bPohang Accelerator Laboratory, Pohang University of Science and Technology, Pohang 37673, Korea

^cDepartment of Physics Education, Pusan National University, Busan 46241, Korea

^dResearch Institute for Electronic Science, Hokkaido University, Sapporo 001–0020, Japan

^eResearch Center for Dielectric and Advanced Matter Physics, Pusan National University, Busan 46241, Korea

*Email: hiromichi.ohta@es.hokudai.ac.jp, hjeen@pusan.ac.kr

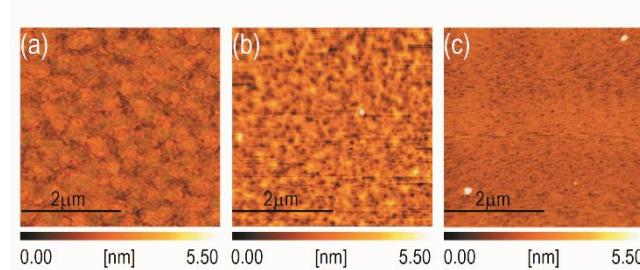


Fig S1. Topographic AFM images of (a) SFCO, (b) STO/SFCO, and (c) NSMO/SFCO films.

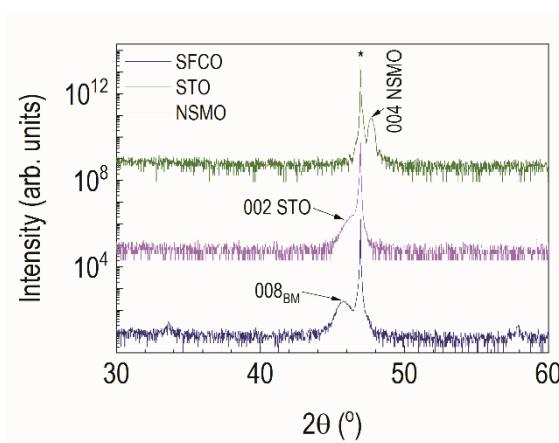


Fig S2. XRD patterns of SFCO (navy line), STO (magenta line) and NSMO (olive line).

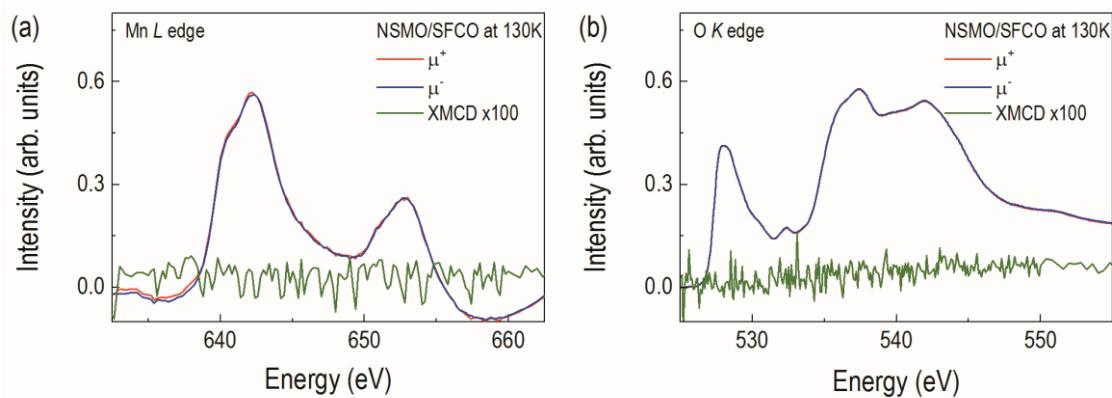


Fig S3. (a) Mn *L* edge and (b) O *K* edge XMCD spectra of an NSMO/SFCO. The XMCD spectra of Mn *L* edge and O *K* edge are multiplied 100 times, but there is no ferromagnetic signal.